History of the Nitto Denko Group

Nitto Denko Corporation began its operation aiming to produce domestic electrical insulation material in Ohsaki, Tokyo in 1918. Since then with ongoing technical innovation and the introduction of advanced technologies, we have grown and expanded into what is now the current Nitto Denko Group.

1918

Nitto Electric Industrial Co., Ltd. starts business in Ohsaki, Tokyo.



1918: Ohsaki head office and the plant at that time

1941

Ibaraki Plant in Osaka begins operation.

1945

Head office in Ohsaki is destroyed by air raids.

The First Change Period-Multi Lateralization of Business ("Second Establishment")

1946

Head office is relocated to Ibaraki-shi, Osaka (the present Ibaraki Plant).



1946
Beginning of commercial production of friction tape

1950

1940



1962 The present Toyohashi Plant

1961

Nitto Denko opens its first overseas office in New York.

1962

Toyohashi Plant begins operation.

Listed as a common stock on Second Sections of the Tokyo and Osaka Stock Exchanges.

1967

Kanto Plant begins operation.

Listed as a common stock on First Sections of the Tokyo and Osaka Stock Exchanges.

1969

Establishment of the first overseas production base;

Nitto Denko (Taiwan) Corporation.

Establishment of Nitto Denko America Inc.

Kameyama Plant begins operation.

1973

Beginning research and development into membrane technologies and products.

The Second Change Period-

Overseas Deployment

1974

Establishment of Nitto Belgium NV (the present Nitto Europe NV).



1974 The present Nitto Europe N\

1975

Establishment of Nitoms Inc.

Production of polarizing films for liquid crystal displays begins.

1970

1977

Tohoku Plant begins operation.



1977 The present Tohoku Plant

1982

Kyushu Nitto Denko (the present Nitto Electronics Kyushu Co., Ltd.) begins operation.

1960



1967 The present Kanto Plant



1969 The present Kameyama Plant

1910

1983

Beginning of production of transdermal drug delivery patches.

1986

Shiga Plant begins operation as the world's first plant specializing in membrane production.



1986 The present Shiga Plant

1987

Acquisition of Hydranautics in the USA.

1988

Acquisition of Permacel in the USA.

70th anniversary of the founding Company name altered to Nitto Denko Corporation.

1980

The Third Change Period-Return to Our Core Business-Introduction of Division System

1989

Development of plant tissue culture technology.

1994

Establishment of a sales and processing base in China

1996

Onomichi Plant begins operation. Introduction of department system



1996 The present Onomichi Plant

The Fourth Change Period-Technology-oriented Company

1997

Seven domestic plants obtain ISO 9000 Series certification.

1998

Construction of Adhesive Tape Research & Technology Center at the Toyohashi Plant.



1998 Adhesive Tape Research & Technology Center

1990

1999

Establishment of Nitto Denko Packaging System Corporation.

Establishment of Korea Nitto Optical Co., Ltd.

2000

Establishment of Nitto Denko Himawari Co., Ltd.



2000 Nitto Denko Himawari Co., Ltd.

The Fifth Change Period-Period of Globalization

2002

Initiation of spiral RO element module assembly in Shanghai Song Jiang in China.

2005

Received the Prime Minister Prize for "invention of the method of manufacturing wide-view-angle birefringent film for LCDs".



2005 Presentation ceremony

2000

2006

Head office is relocated to Osaka City.

2007

Kyoshin Corporation, one of the group companies, and Nitto Denko Matex Corporation are consolidated into Nitto Denko Corporation.

Establishment of Kathyd Technology LLC with Mitsubishi Rayon Engineering Co., Ltd.

2008

Awarded 2007 Nikkei Superior Products and Services Awards for Seawater Desalination Membrane "SWC5"

Establishment of R&D center for water processing business in Singapore

Establishment of Nitto Denko Asia Technical Center Pte. Ltd.